C_2H_4 Insertion into Pt^{II} -SiH₃ and Pt^{II} -H Bonds. An ab Initio MO/MP4 Study

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Received February 7, 1994®

Abstract: Insertion reactions of C_2H_4 into the Pt-H and Pt-SiH₃ bonds of a platinum(II) hydride silvl ethene complex, $PtH(SiH_3)(PH_3)(C_2H_4)$, are investigated with the ab initio MO/MP4SDQ method. When the H ligand lies at the position trans to C_2H_4 , C_2H_4 is inserted into the Pt-SiH₃ bond with a significantly high activation energy (E_a) of 54 kcal/mol. When SiH₃ lies at the position trans to C_2H_4 , C_2H_4 is inserted into the Pt-H bond with much lower E_a (21 kcal/mol). Although the product just after the insertion involves a strong $Pt-H^{\beta}$ agostic interaction, deinsertion of C_2H_4 occurs with nearly no barrier. To complete hydrosilation of ethene, further conversion to the most stable product must occur by breaking the agostic interaction of about 17 kcal/mol. The total E_a of 38 (21 + 17) kcal/mol is lower than the E_a of the above-mentioned C₂H₄ insertion into the Pt-SiH₃ bond. When PH₃ is at the position trans to C₂H₄, C_2H_4 is inserted into the Pt-SiH₃ bond with E_a of 16.2 kcal/mol and into the Pt-H bond with E_a of only 4.4 kcal/mol. These results lead to the conclusions that ethene is much more easily inserted into the Pt-H bond than it is into the Pt-SiH₃ bond and that the Pt-catalyzed hydrosilation of alkene proceeds through the Chalk-Harrod mechanism. Determining factors for the ease of the insertion are the Si-C and C-H bond energies, the trans-influence of the ligand at the position trans to C_2H_4 , the directionality of valence orbitals of H and SiH₃, and sometimes the agostic interaction between Pt and the C_2H_5 group formed in the reaction.

I. Introduction

The insertion reaction of alkene into M-H and M-SiH₃ bonds is of fundamental importance in the chemistry of hydrosilation of alkene.¹ For instance, it has been actively discussed whether alkene is inserted into the M-H bond (Chalk-Harrod mechanism)1-3 or into the M-SiH3 bond (modified Chalk-Harrod mechanism).⁴ In this regard, detailed knowledge of the alkene insertion into the M-H and M-SiH₃ bonds is necessary for understanding well the hydrosilation of alkene and making further developments in the catalytic synthesis of Si compounds. Theoretical investigation is expected to offer valuable information, including the geometry of transition state, the activation energy, the energy of reaction, electron redistribution, etc., of the alkene insertion into M-SiH₃ and M-H bonds. However, the alkene insertion into the M-SiH₃ bond has not been theoretically investigated to our knowledge.

In this work, insertion reactions of C_2H_4 into the Pt-SiH₃ and Pt-H bonds of a platinum(II) hydride silyl ethene complex, PtH- $(SiH_3)(PH_3)(C_2H_4)$ (1), are theoretically investigated with the ab initio MO/MP4SDQ method. 1 is selected here because the

 $PtH(SiH_3)(PH_3)(C_2H_4) \rightarrow Pt(CH_2CH_2SiH_3)(H)(PH_3) \text{ or }$ \rightarrow Pt(CH₂CH₃)(SiH₃)(PH₃) (1)

insertion reaction of ethene into a metal-hydride bond has been theoretically investigated in similar four-coordinate Pt(II) and

Pd(II) complexes,^{5,6} and the ethene insertion has been experimentally^{7,8} and theoretically⁵ reported to occur easily in fourcoordinate Pt(II) complexes. Our aims are (1) to show which bond easily undergoes the C_2H_4 insertion, Pt-H or Pt-SiH₃; (2) to estimate the activation energy (E_a) and the energy of reaction (ΔE) ; and (3) to clarify determining factors for the ease of the insertion.

II. Computational Details

Geometries of reactants, transition state (TS), and products were optimized at the Hartree-Fock (HF) level with the energy gradient technique, where a C_s symmetry constraint was adopted. Some geometries were reoptimized at the MP2 level. TS was determined by calculating the Hessian matrix. In all the calculations, the geometry of PH₃ was taken to be the same as the experimental structure of the free PH3 molecule.9 MP4SDQ calculations were performed with all core orbitals excluded from an active space. Although MP4SDTQ calculations were also carried out for several complexes in order to examine the contribution of triple excitations, no significant difference between MP4SDQ and MP4SDTQ was observed (vide infra). Gaussian 8610 and 9211 programs were used for these calculations.

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[•] Abstract published in Advance ACS Abstracts, July 1, 1994.

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Figure 1. Optimized geometries of PtH(SiH₃)(PH₃)(C₂H₄) (1) and PtH(SiH₃)(PH₃) (2). Bond lengths in Å. Bond angles are omitted here for brevity.17

Two kinds of basis sets, BS I and BS II, were used in this work. In BS I, the core electrons (up to 4f) of Pt were replaced with the relativistic effective core potentials (ECPs) of Hay and Wadt, and the valence orbitals of Pt (5s, 5p, 5d, 6s, and 6p) were represented with a (5s 5p 3d)/[3s 3p 2d] set.¹² For C and Si, MIDI-3 sets were used,¹³ while a MINI-1 set was employed for P.13 A (4s)/[2s] set14 was used for H, except H of PH₃, for which a minimal (3s)/[1s] set15 was employed. In BS II, a (5s 5p 3d)/[3s 3p 3d] set was used for valence orbitals of Pt, where core electrons (up to 4f) of Pt were replaced with the same ECPs as in BS I.12 For C, Si, and P, MIDI-4 sets were adopted.¹³ A (4s)/[2s] set¹⁴ was used for H. A p-polarization function ($\zeta = 1.0$)¹⁴ was added to the basis set of an active H atom which coordinates to Pt only when it reacts with ethene. The basis set for Si was augmented with a d-polarization function in both BS I and BS II.16

III. Results and Discussion

Relative Stabilities of Three Isomers of PtH(SiH₃)(PH₃)(C₂H₄) (1). There are three isomers in $PtH(SiH_3)(PH_3)(C_2H_4)$ (1), as shown in Figure 1:17 C₂H₄ lies at the trans-position of H in 1A, at the trans-position of SiH₃ in 1B, and at the trans-position of PH_3 in 1C. In 1A-1C, ethene is on the molecular plane. The other structure, in which ethene is perpendicular to the molecular plane, is less stable than the in-plane structures by 2.0 kcal/mol for 1A and 1B and by 8.4 kcal/mol for 1C. Although the energy difference between 1A and 1B is less than 0.1 kcal/mol (Table 1), 1C is less stable than 1A and 1B by ca. 12 kcal/mol (at the MP4SDQ level).

Electron distribution and geometries of 1A, 1B, and 1C will be inspected here to clarify the reason that 1C is less stable than 1A and 1B. As compared in Table 1, electron populations of H and SiH₃ ligands of 1C are larger but electron populations of PH₃ and C_2H_4 of 1C are smaller than those of 1A and 1B. This means that 1C involves the weaker charge-transfer interactions from H and SiH₃ to Pt and the stronger charge-transfer interactions from PH_3 and C_2H_4 to Pt than those of 1A and 1B. Consistent with

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(17) Optimized bond angles are given in the supplementary material.

Table 1. Relative Energy (ΔE) and Electron Populations of PtH(SiH₃)(PH₃)(C₂H₄) (1) and Energy Level of LUMO (ϵ_{LUMO}) of PtH(SiH₃)(PH₃)

	1A	1B	1C
ΔE^a (kcal/mol)	0.04	0.0 ^b	12.2
electron population			
Pt	18.498	18.484	18.574
н	0.940	0.978	0.993
SiH ₃	16.940	16.939	17.014
PH ₃	17.769	17.733	17.596
C ₂ H ₄	15.854	15.866	15.823
ε _{LUMO} (eV)	0.82	1.12	0.26

^a MP4SDQ. A positive value means destabilization in energy (vice versa). b-829.7012 hartrees at the MP4SD2 level.

this electron distribution, 1C has the longest Pt-H and Pt-SiH₃ bonds and the shortest Pt-PH₃ bond among three isomers, as shown in Figure 1. These results clearly show that the H and SiH₃ ligands weaken the coordinate bond of the ligand lying at their trans-position; in other words, trans-influence of the H and SiH₃ ligands is strong. The strong trans-influence of the H and SiH₃ ligands is also reflected in the LUMO of PtH(SiH₃)(PH₃) (2): its orbital energy (ϵ_{LUMO}) is 0.82 eV for 2A, 1.12 eV for 2B, and 0.26 eV for 2C, where a vacant site is trans to H in 2A, trans to SiH₃ in 2B, and trans to PH₃ in 2C (see Figure 1 for 2A-2C). This LUMO consists mainly of the Pt d σ orbital, and an incoming ligand coordinates to Pt through the charge-transfer interaction with this LUMO. Because ϵ_{LUMO} increases in the order 2C \ll 2A < 2B, coordination of an incoming ligand would become strong in the order $2B < 2A \ll 2C$. This means that the trans-influence becomes stronger in the order $PH_3 \ll H < SiH_3$ (note that the coordination site is trans to H in 2A, trans to SiH₃ in 2B, and trans to PH_3 in 2C). The situation of 1C is the worst for the trans-influence because the H and SiH₃ ligands, both having strong trans-influence, lie trans to each other. This would be a main reason that 1C is less stable than 1A and 1B. The transinfluence of H, SiH₃, and PH₃ ligands also exerts significant effects on the C₂H₄ insertion into the Pt-H and Pt-SiH₃ bonds, as will be shown below.

C₂H₄ Insertion into the Pt-SiH₃ Bond of 1A. C₂H₄ can be inserted into the Pt-SiH₃ bond in 1A and 1C and into the Pt-H bond in 1B and 1C. We will investigate first the C_2H_4 insertion into the Pt-SiH₃ bond of 1A.

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¹⁰⁸



(The most stable product)

Figure 2. Optimized geometries of the transition state TSA and products of the C_2H_4 insertion into the $Pt-SiH_3$ bond of $PtH(SiH_3)(PH_3)(C_2H_4)$ (1A). (See Figure 1 for 1A. The MP2-optimized values are given in parentheses.) Bond lengths in Å. Bond angles are omitted here.¹⁷

Optimized geometries of transition state (TSA) and possible products (P1-P5) are shown in Figure 2.17 At TSA, C2H4 moves toward SiH₃, the Pt-C¹ distance (2.09 Å) is considerably short, like it is in P1, and the C1-C2 distance (1.53 Å) is only 0.05 Å shorter than it is in P1. The Pt-SiH₃ distance is considerably long, the SiH3 group is changing its direction toward C2H4, and the Si-C² distance (2.06 Å) is only 0.17 Å longer than that in P1. All these features indicate that TSA is product-like and that the Pt-(σ -alkyl) bond is already formed at TSA. The Pt-PH₃ distance becomes shorter but the Pt-H distance becomes longer at TSA. These geometrical changes are interpreted in terms of trans-influence: because the Pt-SiH₃ bond is getting longer in the reaction, the trans-influence of SiH₃ is getting less effective, which strengthens the Pt-PH₃ bond. On the other hand, the Pt-H bond is getting weaker because the σ -alkyl group is gradually formed at the position trans to the Pt-H bond. Accordingly, the Pt-H bond becomes longer but the Pt-PH3 bond becomes shorter in the reaction.

In P1, the distance between Pt and H $^{\gamma}$ of SiH₃ is only 1.72 Å, suggesting that the Pt-H $^{\gamma}$ agostic interaction is considerably strong. P2, in which the Pt-H $^{\gamma}$ agostic interaction disappears (Figure 2), is calculated to be less stable than P1 by ca. 19 kcal/ mol (MP4SDQ). This value slightly increases to 19.7 kcal/mol when a p-function is added to the basis set of H $^{\gamma}$. Thus, the strength of the Pt-H $^{\gamma}$ agostic interaction in P1 is estimated to be ca. 19 kcal/mol.

Although TSA of this reaction is product-like, the Pt-H γ agostic interaction is not yet formed at TSA. To examine carefully the agostic interaction in TSA, we reoptimized the geometry of TSA at the MP2 level (see values in parentheses of Figure 2). The Pt-H γ distances becomes shorter (2.52 Å), but it is still too long to form the agostic interaction. Furthermore, the Si-H γ bond distance (1.48 Å) is almost the same as the other Si-H bond distances. These geometrical features clearly show that TSA does not involve the Pt-H γ agostic interaction. The activation energy (E_a) was calculated at the MP4SDQ level to be 53.9 kcal/ mol for the HF-optimized geometry and 56.5 kcal/mol for the MP2-optimized geometry (Table 2).

The reductive elimination of H-CH₂CH₂SiH₃, which must occur to complete the hydrosilation of alkene, cannot take place in P1 and P2. Besides P1 and P2, there are three possible products (P3-P5 in Figure 2) in which the reductive elimination can occur. In them, P5 is the most stable, because the trans-position of the H ligand is empty and the strong Pt-H γ agostic interaction is

Table 2. Energy Changes by C_2H_4 Insertion into $Pt-SiH_3$ or Pt-H Bond $(kcal/mol)^a$

complex ^b	HF	MP2	MP3	MP4DQ	MP4SDQ
	(A) C	H4 Insert	ion into P	t-SiH3 of 1A	N
1A	0.0 ^c	0.0 ^d	0.0e	0.0	0.08
TSA	45.9	54.9	50.2	53.4	53.9
P1	21.7	31.3	27.0	29.8	30.5
P2	32.8	51.4	44.7	48.4	49.3
P3	12.5	23.0	18.0	20.6	21.5
P4	8.6	20.4	15.0	17.9	18.9
P5	6.4	13.8	9.7	12.1	12.8
	(B)	C ₂ H ₄ Ins	ertion into	Pt-H of 1B	
1 B	0.0 ^h	0.04	0.0/	0.0 ^k	0.01
TSB	20.1	19.7	18.6	20.3	20.6
P6	20.1	20.0	19.7	20.5	20.8
P7	26.6	40.5	33.9	36.8	37.6
P8	1.3	5.7	2.3	3.8	4.3
P9	-8.7	-6.1	-7.9	-6.7	-6.5
P10	-6.8	-4.8	-6.5	-5.3	-5.1
	(C)	C ₂ H ₄ Inser	tion into l	Pt-SiH ₃ of 1	С
1C	0.0m	0.0"	0.00	0.0	0.04
TSC	17.8	16.2	15.0	16.2	16.3 (16.3)
P5	-6.3	2.4	-2.0	-0.2	0.6 (2.9)
	(D)	C ₂ H ₄ Ins	ertion into	Pt-H of 1C	2
1C	0.0m	0.0"	0.00	0.0	0.09
TSD	5.1	4.0	4.6	4.6	4.4 (4.2)
P10	-21.6	-19.7	-19.4	-18.6	-18.4
P9	-23.5	-18.0	-20.8	-20.0	-20.0 (-17.2)

^a A positive value means destabilization in energy (and vice versa). ^b See Figures 2, 4, and 6. c-829.1277. ^d-829.6405. e-829.6657. ^f-829.6902. e-829.7011. ^h-829.1304. i-829.6395. ^j-829.6659. ^k-829.6903. ^l-829.7012. m-829.1074. ⁿ-829.6224. c-829.6470. ^p-829.6707. e-829.6817. ^r In parentheses are values from MP4SDTQ (-829.7040 for 1C). All these values are given in hartrees.

involved in **P5**. **P5** is, however, less stable than **1A** by 12.8 kcal/ mol (MP4SDQ).

Isomerization from P1 to P5 would occur after loss of the Pt-H γ agostic interaction because the Pt-H γ agostic interaction would suppress the isomerization. Thus, we examined the isomerization using PtH(CH₃)(PH₃) as a model. Geometries of P2', P3', and P4' and transition states of the isomerizations are given in Figure 3, ¹⁷ where P2', etc., means a model of P2, etc. As shown in Figure 3, P2' isomerizes to P3' with E_a of 11.6 kcal/mol at the HF level and E_a of 2.8 kcal/mol at the MP4SDQ level, and then P3' isomerizes to P4' with E_a of 6.8 kcal/mol at



Figure 3. Optimized geometries of three isomers of $PtH(CH_3)(PH_3)$ and the transition states of isomerization between them. Bond lengths in Å. Bond angles are omitted here.¹⁷

the HF level and E_a of 5.3 kcal/mol at the MP4SDQ level. On the other hand, **P2'** directly isomerizes to **P4'** (the most stable isomer) with E_a of 3.8 kcal/mol at the HF level but no barrier at the MP4SDQ level. Thus, P1 would isomerize to P4 with no barrier immediately when the agostic interaction of 19 kcal/mol is lost. Further isomerization from P4 to P5 would occur very easily, because only a rotation around the C-C bond is necessary in the isomerization. Because deinsertion of ethene from P1 to 1A needs E_a of 23 kcal/mol (Table 2), isomerization from P1 to P5 occurs more easily than the deinsertion.

In conclusion, the C_2H_4 insertion into Pt-SiH₃ of 1A occurs with a significantly high activation energy of 54 kcal/mol to yield P1, followed by further isomerization to P5 to complete the hydrosilation of ethene, as summarized in Scheme 1(A). Thus, this reaction is very difficult.

C2H4 Insertion into the Pt-H Bond of 1B. Optimized geometries of transition state (TSB) and products (P6-P10) are shown in Figure 4.17 At TSB, the C-C, Pt-C, and C-H distances are almost the same as those of P6, and an energy difference between TSB and P6 is very small (Table 2). These results indicate that P6 easily causes deinsertion of ethene with nearly no barrier. This is probably because the alkyl group is formed at the transposition of SiH₃ (remember that trans-influence of alkyl and SiH₃ ligands is very strong). In both TSB and P6, the Pt-H^{β} distance (about 1.8 Å) is only 0.1–0.2 Å longer than the Pt-H bond of 1B, and the C-H^{β} distance (1.25 Å) is much longer than the usual C-H bond distance. These geometrical features indicate that a strong Pt-H^{β} agostic interaction is involved in TSB and P6. The strength of this agostic interaction is estimated to be ca. 17 kcal/mol because P6 is 16.8 kcal/mol more stable than P7, which does not involve this agostic interaction. In spite of





Scheme 1^a



(A) C_2H_4 insertion into Pt-SiH₃ in **1A** (B) C_2H_4 insertion into Pt-H in **1B**

(C) C₂H₄ insertion into Pt-H (solid line) or Pt-SiH₃ (dotted line) in **1C**

^a Numbers represent energy difference in kcal/mol from MP4SDQ. Those in parentheses are from MP4SDTQ.



Figure 5. Optimized geometries of three isomers of $Pt(CH_3)(SiH_3)$ -(PH₃) and the transition states of isomerization between them. Bond lengths in Å. Bond angles are omitted here.¹⁷

this strong agostic interaction, both **TSB** and **P6** are significantly less stable than **1B** by ca. 21 kcal/mol.

The reductive elimination of $H_3Si-CH_2CH_3$, which must occur to complete the hydrosilation of alkene, cannot take place in P6 and P7. Besides P6 and P7, there are three isomers, P8, P9, and P10 (Figure 4), in which the reductive elimination can occur. In them, P9 is the most stable, since the trans-position to SiH₃ is empty. The Pt-H^{β} agostic interaction is not involved in it, probably because SiH₃ lying at the trans-position of H^{β} disfavors the formation of agostic interaction due to its strong transinfluence. P9 is 6.5 kcal/mol more stable than 1B (Table 2). Thus, insertion 1B \rightarrow P9 is exothermic.

We next investigate isomerization from P6 to P9. This isomerization would occur after loss of the agostic interaction in P6, because the agostic interaction suppresses the isomerization. Thus, we examined isomerization from P7 to P9, using Pt(PH₃)-(SiH₃)(CH₃) as a model. Optimized geometries of Pt(PH₃)-(SiH₃)(CH₃) and the TS of the isomerization are shown in Figure 5.17 The activation energy was calculated to be 7.0 kcal/mol at the HF level and 1.1 kcal/mol at the MP4SDQ level for isomerization from P7' to P8', 3.1 kcal/mol at the HF level and 1.9 kcal/mol at the MP4SDQ level for isomerization from P8' to P9', and 4.0 kcal/mol at the HF level and no barrier at the MP4SDQ level for the direct isomerization from P7' to P9' (the most stable product). Thus, isomerization from P6 to P9 would easily occur with nearly no barrier after loss of the Pt-H^β agostic interaction. About 17 kcal/mol (MP4SDQ) is necessary to break the agostic interaction (remember that the strength of the Pt-H^{β} agostic interaction is about 17 kcal/mol). This value is higher than the activation barrier of the de-insertion of ethene (vide supra).

In conclusion, ethene is inserted into the Pt-H bond with an activation energy of 21 kcal/mol, to yield P6, followed by isomerization $P6 \rightarrow P9$ which causes energy destabilization of 17 kcal/mol to break the Pt-H^{β} agostic interaction. The total activation energy for reaction $1B \rightarrow P9$ is 38 kcal/mol (= 21 + 17 kcal/mol),¹⁸ as shown in Scheme 1(B). These results lead to the conclusion that C₂H₄ is much more easily inserted into the Pt-H bond of 1B than it is into the Pt-SiH₃ bond of 1A.

 C_2H_4 Insertion into the Pt-H or Pt-SiH₃ Bond of 1C. In 1C, ethene is inserted into the Pt-SiH₃ bond, to yield product P5

through transition state TSC (Figure 6).¹⁷ TSC resembles TSA, while TSC includes a shorter C-C distance and a longer C-Si distance than those of TSA. Because P5 is the most stable in PtH(PH₃)(CH₂CH₂SiH₃) and can cause reductive elimination of H-CH₂CH₂SiH₃ (see above), we do not need to consider any isomerization. As shown in Table 2, this insertion occurs with an activation energy of 16.3 (16.3) kcal/mol and endothermicity of 0.6 (2.9) kcal/mol at the MP4SDQ level, where results at the MP4SDTQ level are given in parentheses.

The C₂H₄ insertion into the Pt-H bond occurs through transition state **TSD**, yielding product **P10** (Figure 6). The geometry of **TSD** differs somewhat from that of **TSB**; for instance, the C-C distance is considerably shorter, and the C-H distance is much longer, but the Pt-H distance is shorter than those in **TSB**, indicating that **TSD** is relatively reactant-like. **P10** is slightly less stable than **P9** (vide supra). However, isomerization **P10** \rightarrow **P9** needs only the rotation around the C-C bond, which would occur with no barrier. Thus, **TSD** is the true transition state of reaction **1C** \rightarrow **P9**, and this reaction takes place with E_a of 4.4 (4.2) kcal/mol and E_{exo} of 20.0 (17.2) kcal/mol at the MP4SDQ level (Table 2), where the MP4SDTQ results are given in parentheses.

In conclusion, ethene is easily inserted into the Pt-H and Pt-SiH₃ bonds in 1C, and the insertion into the Pt-H bond occurs more easily than that into the Pt-SiH₃ bond, as shown in Scheme 1(C).

Factors Determining the Energy of Reaction (ΔE). In the C_2H_4 insertion into the Pt-SiH₃ bond, the Si-C and Pt-C bonds are newly formed, but the Pt-SiH₃ bond is broken. In the C_2H_4 insertion into the Pt-H bond, the C-H and Pt-C bonds are newly formed, but the Pt-H bond is broken. Thus, the difference in ΔE between two insertion reactions would depend on these bond energies (note that the change of a C=C double bond to a C-C single bond is common in all the insertion reactions examined). These bond energies have been estimated in our previous theoretical work¹⁹ on the basis of following reactions.

 $Pt(PH_3)_2 + H_2 \rightarrow cis-Pt(H)_2(PH_3)_2$ (2)

 $Pt(PH_3)_2 + CH_3CH_3 \rightarrow cis-Pt(CH_3)_2(PH_3)_2$ (3)

 $Pt(PH_3)_2 + SiH_3 - SiH_3 \rightarrow cis - Pt(SiH_3)_2(PH_3)_2 \quad (4)$

$$H-CH_3 \rightarrow H + CH_3$$
(5)

$$H_3Si-CH_3 \rightarrow SiH_3 + CH_3$$
(6)

As is clearly shown in Scheme 2, the E(Pt-Si) value is similar to the E(Pt-H) value, but the E(C-H) value is larger than the E(Si-C) value. From these results, one might conclude that the C_2H_4 insertion into the Pt-H bond is more exothermic (or less endothermic) than that into the Pt-SiH3 bond because the former yields the stronger C-H bond and the latter the weaker Si-C bond. To certify this conclusion, we compare several reactions whose products do not involve agostic interaction. Certainly, reaction of $1B \rightarrow P9$ (C₂H₄ insertion into the Pt-H bond; E_{exo} = ca. 7 kcal/mol) is more exothermic than reaction of $1A \rightarrow P4$ $(C_2H_4 \text{ insertion into the Pt-SiH}_3 \text{ bond}; E_{endo} = ca. 19 \text{ kcal/mol})$ (Table 2); the difference in ΔE between these two reactions roughly corresponds to the difference between C-Si and C-H bond energies. Also, reaction of $1C \rightarrow P9$ (C₂H₄ insertion into the Pt-H bond; $E_{exo} = ca. 20 \text{ kcal/mol}$ is more exothermic than reaction of $1C \rightarrow P4$ (C₂H₄ insertion into the Pt-SiH₃ bond;

⁽¹⁸⁾ The other aspect seems possible, as follows. Because P6 is less stable than 1B by 21 kcal/mol and there is no activation barrier between them, P6 considered to be in thermal equilibrium with 1B. If so, the activation energy to yield P9 is about 17 kcal/mol.

^{(19) (}a) Sakaki, S.; Ieki, M. J. Am. Chem. Soc. 1993, 115, 2373. (b) E(Pt-SiH₃) reported in ref 19a was slightly larger than the present value because of our careless miss in ref 19a. (c) These values differ from those in ref 19a because a p-polarization function is added to H in the present work. (20) Walsh, R. Acc. Chem. Res. 1981, 14, 246.

⁽²¹⁾ Golden, D. M.; Benson, S. W. Chem. Rev. 1969, 69, 125.



Figure 6. Optimized geometries of the transition states TSC and TSD and products of the C_2H_4 insertion into either the Pt-SiH₃ or Pt-H bond of 1C. (See Figure 1 for 1C). Bond lengths in Å. Bond angles are omitted here.¹⁷ Orientation of PH₃ is different from that of P5 and P10 shown in Figures 2 and 4.

Se	homo	78
30	neme	4

$Pt(H)(SiH_3)(PH_3)(C_2H_4)$		\longrightarrow Pt(H)(CH ₂ CH ₂ SiH ₃)(PH ₃)		
MP2 MP3 MP4DQ MP4SDQ MP4SDTQ	E(Pt-SiH ₃) 58 55 56 56 58	E(Pt-CH ₃) 42 40 40 40 40 41	E(C-Si) 83 81 80 81 82 (88.2) ²⁰	
Pt(H)	$(SiH_3)(PH_3)(C_2H_4)$	\longrightarrow Pt(SiH	H_3)(CH ₂ CH ₃)(PH ₃)	
MP2 MP3 MP4DQ MP4SDQ MP4SDTQ	E(Pt-H) 60 62 62 62 62 61	E(Pt-CH ₃) 42 40 39 40 41	E(C-H) 107 108 108 108 108 (104) ²¹	
PtH(C	H ₃)(PH ₃)(C ₂ H ₄)	\longrightarrow PtH(CH	$I_2CH_2CH_3$) (PH ₃)	
MP2 MP3 MP4DQ MP4SDQ MP4SDTQ	E(Pt-CH ₃) 42 42 39 40 41	E(Pt-CH ₃) 42 42 39 40 41	E(C-C) 87 85 85 85 86 (88) ²⁰	

^a Values are given in kcal/mol. Experimental values are in parentheses. See ref 19.

 $E_{endo} = ca. 9 \text{ kcal/mol}$. Some discrepancies between the difference in ΔE and the difference in bond energies would be due to the trans-influence and strengthening of the Pt-SiH₃ bond by the reaction $1C \rightarrow P9$ (similar discussion is given below).

The next important factor is the trans-influence of the ligand. For instance, relative stabilities of P2, P3, and P4 depend on the ligand lying at the position trans to the Pt–C bond; P2 is the least stable because the H ligand lies at the position trans to the Pt–C bond (Figure 2). On the other hand, the trans-position of the Pt–C bond is empty in P3 but occupied by PH₃ in P4 (remember, the trans-influence becomes stronger in the order PH₃ \ll H <SiH₃). Similarly, relative stabilities of P7, P8, and P9 are determined by the ligand lying at the trans-position of SiH₃; in these complexes, P9 is the most stable because the trans-position of SiH₃ is empty (Figure 4), P8 is the next most stable because the trans-position of C₂H₅ is empty but the trans-position of SiH₃ is occupied by PH₃, and P7 is the least stable because two strong C_2H_5 and SiH₃ ligands lie trans to each other.

The third important factor is the agostic interaction. Its strength depends on the ligand lying at the trans-position of the agostic interaction. For instance, the strength of the Pt-H^{γ} agostic interaction is estimated to be ca. 19 kcal/mol when PH₃ lies at the position trans to the Pt-H^{γ} interaction (compare P1 and P2 in Figure 2), but only ca. 6 kcal/mol when H is at the position trans to this interaction (compare P4 and P5 in Figure 2). The strength of Pt-H^{β} agostic interaction is estimated to be 17 kcal/mol when PH₃ lies at the position trans to the Pt-H^{β} interaction (compare P6 and P7 in Figure 4) but almost zero when SiH₃ lies at the position trans to this interaction (compare P9 and P10 in Figure 4).

Considering the three factors mentioned above, we can explain the ΔE value of the insertion reaction. The most exothermic reaction is the C₂H₄ insertion into the Pt-H bond, $\mathbf{1C} \rightarrow \mathbf{P9}$. This is because the strong C-H bond is formed and the trans-position of SiH₃ is empty in **P9** (Figure 4). The next is the C₂H₄ insertion into the Pt-SiH₃ bond, $\mathbf{1C} \rightarrow \mathbf{P5}$ (Figure 6). This reaction is less exothermic than reaction of $\mathbf{1C} \rightarrow \mathbf{P9}$, because this insertion produces the weak Si-C bond. Although the Pt-H^{γ} agostic interaction is involved in **P5**, this agostic interaction yields energy stabilization of only 6 kcal/mol, which is much smaller than the difference between E(C-H) and E(Si-C) values; accordingly, the agostic interaction does not reverse the order of exothermicity of reactions $\mathbf{1C} \rightarrow \mathbf{P9}$ and $\mathbf{1C} \rightarrow \mathbf{P5}$.

The C₂H₄ insertion into the Pt-H bond of $1B \rightarrow P9$ is exothermic (6.5 kcal/mol), but the C₂H₄ insertion into the Pt-SiH₃ bond of $1A \rightarrow P5$ is endothermic (12.8 kcal/mol); the former produces the weak Si-C bond but the latter the strong C-H bond. However, reaction $1A \rightarrow P5$ yields additional energy stabilization (ca. 6 kcal/mol) by the Pt-H^{γ} agostic interaction. Also, reaction $1B \rightarrow P9$ yields additional stabilization of the Pt-SiH₃ bond, as follows. The Pt-SiH₃ distance shortens to 2.32 Å (in P9) from 2.36 Å (in 1B) in reaction $1B \rightarrow P9$ (Figure 4), whereas the Pt-H distance changes little in reaction $1A \rightarrow P5$ (Figure 2). These geometry changes indicate that the Pt-SiH₃ bond would strengthen in reaction $1B \rightarrow P9$ but the Pt-H bond would not in reaction $1A \rightarrow P5$ and that strengthening of the Pt-SiH₃ bond would yield additional stabilization in **P9**. This additional stabilization would correspond to the additional stabilization of **P5** by the Pt-H γ agostic interaction. Thus, the difference in ΔE between these two reactions (ca. 19 kcal/mol) is roughly in accord with the difference between E(Si-C) and E(C-H) bond energies (ca. 20 kcal/mol).

Reaction of $1A \rightarrow P5$ is more endothermic than reaction of $1C \rightarrow P5$. Both involve C_2H_4 insertion into the Pt-SiH₃ bond. The difference is, therefore, interpreted in terms of trans-influence of H and PH₃. SiH₃ lies at the trans-position of PH₃ in 1A and at the trans-position of H in 1C. Because this unfavorable situation of 1C disappears in the product, reaction of $1C \rightarrow P5$ is less endothermic than reaction of $1A \rightarrow P5$. The difference in ΔE between reactions $1B \rightarrow P9$ and $1C \rightarrow P9$ can be explained in a similar way.

Determining Factors for the Activation Energy (E_a) . In 1C, ethene is inserted into the Pt-H bond with a lower activation energy than that into the Pt-SiH₃ bond. This result is again interpreted in terms of bond energies. The stronger C-H bond is formed in the former, while the weaker Si-C bond is formed in the latter; accordingly, the former E_a is lower than the latter $E_{\rm a}$. The next factor is the directionality of valence orbitals of H and SiH₃;²² as has been pointed previously,¹⁹ SiH₃ has a directional sp³ valence orbital but H has a spherical 1s orbital. At the TS, the Pt-SiH₃ bond must be broken to form a new bond with C₂H₄, while the H ligand can start to interact with C₂H₄, keeping the Pt-H bond. This is one of the reasons that the C₂H₄ insertion into the Pt-SiH₃ bond requires a higher E_a than does that into the Pt-H bond. The third factor is trans-influence of the ligand lying at the trans-position of C_2H_4 . E_a of reaction $1B \rightarrow P6$ (Figure 4) is much higher than E_a of reaction $1C \rightarrow P9$ (Figure 6). Because both reactions involve C_2H_4 insertion into the Pt-H bond, this difference cannot be explained in terms of bond energy and directionality of the valence orbital. In TSB of reaction 1B \rightarrow P6, the Pt-C σ -bond is already formed at the trans-position of SiH₃. In TSD of reaction $1C \rightarrow P9$, on the other hand, the Pt-C σ -bond is getting formed at the trans-position of PH₃. Apparently, TSD is more favorable than TSB from the viewpoint of trans-influence. Also, the difference between two insertion reactions into the Pt-SiH₃ bond can be explained in a similar way, as follows: reaction $1A \rightarrow P1$ requires a higher activation energy than reaction $1C \rightarrow P9$, because the former yields the Pt-C σ -bond at the trans-position of H but the latter yields it at the trans-position of PH₃. These results indicate that the C₂H₄ insertion occurs easily when the ligand lying at the trans-position to C₂H₄ exerts weak trans-influence. The agostic interaction also stabilizes TSB of reaction $1B \rightarrow P6$, while TSs of the other insertion reactions hardly receive energy stabilization from this interaction.

In conclusion, the activation energy is mainly determined by bond energy, the directionality of valence orbitals of H and SiH₃, the ligand lying at the trans-position of C_2H_4 , and sometimes the agostic interaction.

Based on the above discussion, we can compare the C_2H_4 insertion into the Pt-CH₃ bond with that into the Pt-SiH₃ and Pt-H bonds. In the C_2H_4 insertion into the Pt-SiH₃ bond, the strong Pt-SiH₃ bond changes to the weak Pt-CH₂CH₂SiH₃ bond,



(B) Isomerization of Pt(H)(C2H4)(PH3)

Figure 7. Isomerizations of $PtH(SiH_3)(PH_3)$ (2) and $PtH(SiH_3)(C_2H_4)$ (3). Bond lengths in Å. Bond angles are omitted here.¹⁷

as shown in Scheme 2. In the C_2H_4 insertion into the Pt-CH₃ bond, on the other hand, the Pt--CH3 bond changes to a similar Pt-CH₂CH₂CH₃ bond. Thus, the C₂H₄ insertion into the Pt-CH₃ bond is more exothermic than that into the Pt-SiH₃ bond (note that E(C-C) is similar to E(C-Si)). In discussing the E_a value, we need to consider the directionality of valence orbitals of CH₃ and SiH₃. As is known,²² both SiH₃ and CH₃ have a directional sp³ valence orbital. This means that both Pt-SiH₃ and $Pt-CH_3$ bonds must be broken at the TS of the C_2H_4 insertion. Apparently, the weaker Pt-CH₃ bond is more easily broken than the stronger Pt-SiH₃ bond. From these results, we can predict that C₂H₄ is more easily inserted into the Pt-CH₃ bond with lower E_a than it is into the Pt-SiH₃ bond. In the C₂H₄ insertion into the Pt-H bond, the strong Pt-H bond must be broken but the strong C-H bond is formed, while the weak Pt-CH3 bond is broken and the weak C-C bond is formed in the C2H4 insertion into the Pt-CH₃ bond. The difference between E(Pt-H) and $E(Pt-CH_3)$ is slightly larger than the difference between E(C-H) and E(C-C). Thus, we can suggest that the C_2H_4 insertion into the Pt-CH₃ bond is slightly more exothermic than that into the Pt-H bond. Although the Pt-CH₃ bond is weaker than the Pt-H bond, it is not easy to predict which proceeds with lower E_a , the C₂H₄ insertion into the Pt-CH₃ bond or the C₂H₄ insertion into the Pt-H bond, because CH₃ has a directional sp³ valence orbital unlike the spherical 1s orbital of H.

Isomerization from 1A or 1B to 1C. We will address here isomerizations from 1A and 1B to 1C because the C_2H_4 insertion in 1C occurs most easily. This kind of isomerization can proceed through a three-coordinate intermediate. One possible intermediate is PtH(SiH₃)(PH₃) (2) (Figure 1). C_2H_4 dissociates from 1A to yield 2A, with energy destabilization of 23 kcal/mol, and from 1B to yield 2B, with energy destabilization of 16 kcal/ mol, as shown in Scheme 1(C) (hereafter, MP4SDQ values are given). Thus, 2A and 2B are considered to be in thermal

⁽²²⁾ Essentially the same discussion has been presented in previous reports of the H-H, H-CH₃, CH₃-CH₃, and SiH₃-SiH₃ oxidative additions to transition metals^{22a-d} and the CO₂ insertion into the Cu-R bond (R = H or CH₃):^{22a} (a) Blomberg, M. R. A.; Brandemark, U.; Siegbahn, P. E. M. J. Am. Chem. Soc. **1983**, 105, 5557. (b) Saillard, J. Y.; Hoffmann, R. J. Am. Chem. Soc. **1984**, 106, 2006. (c) Low, J. J.; Goddard, W. A. Organometallics **1986**, 5, 609. Low, J. J.; Goddard, W. A. J. Am. Chem. Soc. **1986**, 108, 6115. (d) Reference 23. (e) Sakaki, S.; Ohkubo, K. Organometallics **1989**, 8, 2970.

^{(23) (}a) The strong ligand tends to take an axial site in trigonal-bipyramidal structure.^{23bc} In PtH(SiH₃)(PH₃)₂(C₂H₄), SiH₃ is the strongest ligand. Thus, the structure 4 (see text) is considered to be the most plausible species which is directly formed from 1A and 1B. (b) Rossi, A.; Hoffmann, R. *Inorg. Chem.* 1975, 14, 365. (c) Koga, K.; Jin, S. Q.; Morokuma, K. J. Am. Chem. Soc. 1988, 110, 3417.

equilibrium with 1A and 1B, respectively. TSs of isomerizations $2A \rightarrow 2C$ and $2B \rightarrow 2C$ could be optimized at the HF level but disappeared at the MP2-MP4SDO levels (Figure 7A).¹⁷ This means that 2C converts into 2A or 2B with no barrier. PH₃ coordination to 2C, however, yields 1C as a stable species. Because 2C is less stable than 2A by 35 kcal/mol and 2B by 43 kcal/mol, energies of 35 and 43 kcal/mol are necessary to yield 1C from 2A and 2B, respectively. The other possible intermediate is PtH- $(SiH_3)(C_2H_4)$ (3) (Figure 7B).¹⁷ PH₃ dissociates from 1A to yield 3A, with energy destabilization of 24 kcal/mol, and from 1B to yield 3B, with energy destabilization of 30 kcal/mol. Although TSs of isomerizations of $3A \rightarrow 3C$ and $3B \rightarrow 3C$ could be optimized at the HF levels using BS I, these TSs disappeared at both HF and MP2-MP4SDQ levels using BS II. 3C is less stable than 3A by 40 kcal/mol and 3B by 35 kcal/mol. Thus, isomerizations $1A \rightarrow 1C$ through 3A and $1B \rightarrow 1C$ through 3B require energy destabilizations of 40 and 35 kcal/mol, respectively. Reactions of $2A \rightarrow 2C$ and $3B \rightarrow 3C$ requires smaller energy destabilizations than reactions $3A \rightarrow 3C$ and $3A \rightarrow 3C$, and formation of 2A from 1A needs smaller energy destabilization than that of 3B from 1B. In conclusion, the isomerization of 1A to 1C through 2A occurs most easily, with E_a of ca. 35 kcal/mol, where 2A is considered to be in thermal equilibrium with 1A (Scheme 1(C)). This value is much lower than E_a of the C₂H₄ insertion into the $Pt-SiH_3$ bond of 1A. Because the C_2H_4 insertion into the Pt-H bond of 1C occurs with E_{a} of only 4 kcal/mol, the C_2H_4 insertion into the Pt-H bond takes place easily immediately when 1A isomerizes to 1C (Scheme 1(C)). This means that detection of 1C is very difficult.

Isomerizations of 1A and 1B through a five-coordinate intermediate are also plausible, because a five-coordinate complex easily causes geometry change via Berry pseudorotation. PtH- $(SiH_3)(PH_3)_2(C_2H_4)$ (4) is considered to be a possible candidate for such a five-coordinate species.²¹ We tried to optimize 4, but



one PH₃ ligand on the equatorial site gradually dissociates from Pt during optimization. This suggests that formation of fivecoordinate species would be difficult, although the possibility cannot be neglected completely. Even if the isomerization via five-coordinate species would occur with a lower activation energy than the isomerization via three-coordinate species, no change is made in the conclusion that the C_2H_4 insertion into the Pt-SiH₃ bond of 1A requires a higher activation energy than the isomerization of 1A \rightarrow 1C. When 1C is formed, ethene is much more easily inserted into the Pt-H bond than it is into the Pt-SiH₃ bond (see above). In all cases, therefore, the C_2H_4 insertion into the Pt-SiH₃ bond is difficult. Because the isomerization through a five-coordinate intermediate must be investigated in more detail, we would like to investigate it in our future study.

IV. Concluding Remarks

The Pt-catalyzed hydrosilation of ethene occurs through the Chalk–Harrod mechanism, as follows. First, 1A or 1B is formed through oxidative addition of the Si–H σ -bond to Pt(0). Ethene is then inserted into the Pt–H bond of 1B with an activation energy of ca. 21 kcal/mol (MP4SDQ), followed by isomerization to P9, from which the reductive elimination of H₃Si–CH₂CH₃ takes place to complete the hydrosilation of ethene. The total E_a is about 38 kcal/mol.¹⁸ The other pathway, involving isomerization of 1A to 1C, seems possible. This isomerization would occur with an activation energy of ca. 35 kcal/mol. After the isomerization, ethene can be easily inserted into the Pt–H bond, with an activation energy of only 4 kcal/mol.

The C_2H_4 insertion into the Pt-SiH₃ bond is very difficult in 1A, where its activation energy is 54 kcal/mol. In 1C, also, this insertion is significantly more difficult than the C_2H_4 insertion into the Pt-H bond. Thus, the modified Chalk-Harrod mechanism does not work in the Pt-catalyzed hydrosilation of alkene.

Important factors determining the ease of the insertion are (1) the Si-C and C-H bond energies, (2) the trans-influence of the ligand lying at the trans-position of C_2H_4 , (3) the directionality of the valence orbitals of SiH₃ and H, and sometimes (4) the agostic interaction between Pt and the C-H or Si-H bond. In $PtH(SiH_3)(PH_3)(C_2H_4)$, the Pt-H bond energy is almost the same as the $Pt-SiH_3$ bond energy. Thus, ethene is more easily inserted into the Pt-H bond than it is into the Pt-SiH₃ bond, because the C-H bond is stronger than the Si-C bond and the H ligand has a spherical 1s valence orbital. If the M-H bond is considerably stronger than the M-SiH₃ bond and the difference between M-H and M-SiH₃ bond energies sufficiently exceeds the difference between Si-C and C-H bond energies, then ethene would be inserted into the M-SiH₃ bond. In such a case, transition-metal-catalyzed hydrosilation of alkene would proceed through modified the Chalk-Harrod mechanism.

Acknowledgment. This work was supported in part by a grant from Ministry of Education, Culture, and Science (Grant-in-Aid Nos. 04243102 and 06227256). Calculations were carried out by using the Hitachi S-820 computer of the Institute for Molecular Science and the IBM RS-6000/340 workstation of our laboratory.

Supplementary Material Available: Optimized bond angles (2 pages). This material is contained in many libraries on microfiche, immediately follows this article in the microfilm version of the journal, and can be ordered from the ACS; see any current masthead page for ordering information.